

CLAIMS:

What is claimed is:

1 1. A photodetecting device comprising:
2 a first region of semiconductor material of a first conductivity type;
3 a second region of semiconductor material of a second conductivity
4 type opposite the first conductivity type and extending over a portion of the first
5 region, the device being configured to permit light to enter the second region;
6 third and fourth regions of semiconductor material of the first
7 conductivity type extending over portions of the second region, the third and
8 fourth regions being respectively coupled to first and second electrical contacts.

1 2. The device of claim 1 wherein the first conductivity type is P and
2 the second conductivity type is N.

1 3. The device of claim 1 wherein the third and fourth regions are
2 more heavily doped than the first region.

1 4. A method of using a photocell, comprising
2 exposing the photocell to incident light;
3 driving a sample node of the photocell to a reset value;
4 sensing a monitor node of the photocell, the signal values of the
5 monitor and sample nodes decaying in response to the incident light; and
6 driving the monitor node to a stop value in response to the signal
7 value of the monitor node having decayed to a predetermined value.

5. The method of claim 4 further comprising:
releasing the sample node after driving the sample node to the reset
value;
storing a first time value corresponding to the point in time of
releasing the sample node; and
storing a second time value corresponding to the point in time of
driving the monitor node.

6. The method of claim 4 wherein exposing is started after driving the
sample node.

7. The method of claim 4 further comprising:
reading an output value related to the signal value of the sample
node.

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8. An imaging system comprising:
an image sensor having a plurality of photocells, the photocells
providing sensor signals in response to incident light and control signals, the
photocells being part of an integrated circuit (IC) die, the IC die having a first
region of semiconductor material of a first conductivity type, each of the plurality
of photocells having
a second region of semiconductor material of a second
conductivity type opposite the first conductivity type and extending over a
portion of the first region, the IC die being configured to permit the incident light
to enter the second region,

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11 third and fourth regions of semiconductor material of the
12 first conductivity type extending over portions of the second region, the third
13 and fourth regions respectively coupled to first and second electrical contacts;
14 control circuitry configured to generate the control signals for
15 controlling the image sensor; and
16 signal processing circuitry for generating image data in response to
17 the sensor signals.

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1 9. The imaging system of claim 8 wherein the plurality of photocells
2 define one or more sets of photocells, each set being associated with a respective
3 monitor node, the second contact of each photocell in a set being coupled to the
4 set's respective monitor node, the system being further configured to stop
5 integration in one or more of the sets in response to detecting a predetermined
6 value on the set's respective monitor node.

1 ⁴~~10~~. The imaging system of claim ¹~~8~~ wherein the plurality of photocells
2 define one set associated with a single monitor node.

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1 11. The imaging system of claim 8 wherein the plurality of photocells
2 are arranged as an array and define a plurality of sets, each set defined by a
3 column of the array.

1 12. The imaging system of claim 8 further comprising
2 system controller for controlling the signal processing circuitry.

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13. The imaging system of claim 8 further comprising
optical system configured to receive the incident light to form an
image on the image sensor; and
communication interface for transferring the image data to an
image processing system separate from the imaging system.

14. The imaging system of claim 8 wherein the third and fourth regions
are formed as implants using a MOS fabrication process.

15. The imaging system of claim 1 wherein each photocell further
comprises reset circuit configured to drive a voltage of the first contact to a reset
value in response to a first reset signal.

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16. The imaging system of claim 9 wherein the control circuitry causes
the set's respective monitor node to be pulled high in response to detecting the
predetermined value.

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